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	•			Application Number	Not Yet Assigned	
INF	ORMATI	ON DISC	LOSURE	Filing Date	Concurrently Herewith	
ST	STATEMENT BY APPLICANT			First Named Inventor	Masayasu MIYATA, et al.	
				Art Unit	N/A	
	(Use as many sheets as necessary)			Examiner Name	Not Yet Assigned	
Sheet	1	of	1	Attorney Docket Number	9319A-001729/US/NP	

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